# CONTENTS

## CHAPTER – I \ INTRODUCTION \ 1-33

1.1 Introduction to thin films \ 1
1.2 Transition metal oxides \ 2
1.3 Electrochromic materials \ 3
1.4 Properties, structure and applications of Nb$_2$O$_5$ films: a review \ 5
    1.4.1 Review on the literatures of Nb$_2$O$_5$ films \ 7
    1.4.2 Electrochromism in Nb$_2$O$_5$ films \ 11
1.5 Properties, structure and applications of MoO$_3$ films: a review \ 13
    1.5.1 Review on the literatures of MoO$_3$ films \ 14
    1.5.2 Electrochromism in MoO$_3$ films \ 22
1.6 Nb$_2$O$_5$:MoO$_3$ films \ 23
    1.6.1 Literatures on Nb$_2$O$_5$:MoO$_3$ films \ 24
    1.6.2 Electrochromism in Nb$_2$O$_5$:MoO$_3$ films \ 25
1.7 Scope of the present work \ 26
    References \ 28

## CHAPTER – II \ THIN FILM PREPARATION TECHNIQUES \ 34-46

2.1 Introduction \ 34
2.2 Evaporation method \ 34
2.3 Molecular beam epitaxy \ 34
2.4 Chemical vapor deposition \ 35
2.5 Electroplating \ 35
2.6 Sputtering \ 35
    2.6.1 Physical understanding of sputtering \ 36
    2.6.2 DC diode sputtering \ 37
    2.6.3 RF sputtering \ 37
    2.6.4 Magnetron sputtering \ 38
2.7 Sputtering equipment \ 39
    2.7.1 Vacuum pumps \ 40
2.8 Film preparation \ 42
    2.8.1 Preparation of sputtering targets \ 42
    2.8.2 Substrate selection and cleaning \ 43
    2.8.3 Nb$_2$O$_5$ and Nb$_2$O$_5$:MoO$_3$ film preparation \ 44
2.9 Conclusion \ 45
    References \ 46
CHAPTER – V  OPTICAL AND VIBRATIONAL STUDIES ON
Nb₂O₅ AND Nb₂O₅:MoO₃ THIN FILMS  81-98

5.1 Introduction  81
5.2 Optical transmittance and energy band gap calculation  82
  5.2.1 Nb₂O₅ thin film  82
  5.2.2 Nb₂O₅:MoO₃ (95:5) thin film  85
  5.2.3 Nb₂O₅:MoO₃ (90:10) thin film  87
  5.2.4 Nb₂O₅:MoO₃ (85:15) thin film  88
5.3 Photoluminescence studies on Nb₂O₅ and Nb₂O₅:MoO₃ thin films  89
  5.3.1 Nb₂O₅ thin film  90
  5.3.2 Nb₂O₅:MoO₃ (95:5, 90:10, 85:15) films  90
5.4 Vibrational property of Nb₂O₅ and Nb₂O₅:MoO₃ thin films  92
  5.4.1 Nb₂O₅ thin film  92
  5.4.2 Nb₂O₅:MoO₃ (95:5) thin film  93
  5.4.3 Nb₂O₅:MoO₃ (90:10) thin film  94
  5.4.4 Nb₂O₅:MoO₃ (85:15) thin film  95
5.5 Conclusions  95
References  97

CHAPTER – VI  ELECTROCHROMIC PROPERTIES OF
Nb₂O₅ AND Nb₂O₅:MoO₃ FILMS  99-121

6.1 Introduction  99
  6.1.1 Cyclic voltammetry technique for electrochromic study  101
  6.1.2 Chronocoulometry technique  105
6.2 Electrochromic studies on Nb₂O₅ and Nb₂O₅:MoO₃ thin films  106
6.3 Results of electrochromic studies on Nb₂O₅ films  107
  6.3.1 Intercalation and deintercalation of Li⁺ ion  108
  6.3.2 Intercalation and deintercalation of H⁺ ion  111
6.4 Results of electrochromic studies on Nb₂O₅:MoO₃ films  113
  6.4.1 Intercalation and deintercalation of Li⁺ and H⁺ ions  114
6.5 Conclusions  118
References  119

CHAPTER – VII  SUMMARY, CONCLUSION AND SUGGESTIONS
FOR FUTURE WORK  122-125

7.1 Summary and conclusion  122
7.2 Suggestion for future work  125